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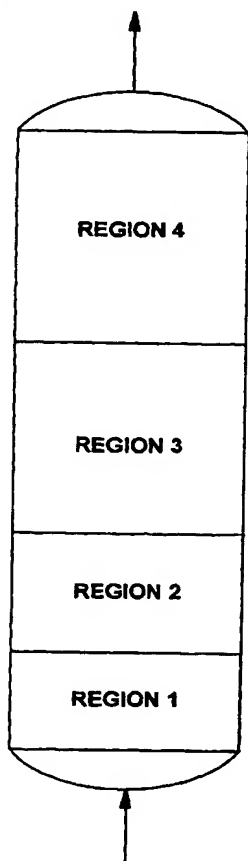
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(54) Title: PROCESS AND APPARATUS FOR HYDROGEN PURIFICATION



(57) Abstract: This invention discloses an optimum set of adsorbents for use in H₂-PSA processes. Each adsorbent bed is divided into four regions; Region 1 contains adsorbent for removing water; Region 2 contains a mixture of strong and weak adsorbents to remove bulk impurities like CO₂; Region 3 contains a high bulk density (>38 lb_m/ft³) adsorbent to remove remaining CO₂; and most of CH₄ and CO present in H₂ containing feed mixtures; and Region 4 contains adsorbent having high Henry's law constants for the final cleanup of N₂ and residual impurities to produce hydrogen at the desired high purity.

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Declarations under Rule 4.17:

- as to applicant's entitlement to apply for and be granted a patent (Rule 4.17(ii)) for the following designations AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, UZ, VC, VN, YU, ZA, ZM, ZW, ARIPO patent (BW, GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK, TR), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG)

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